

Accepted Manuscript

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PII: S1572-6657(17)30927-X

DOI: <https://doi.org/10.1016/j.jelechem.2017.12.052>

Reference: JEAC 3757

To appear in: *Journal of Electroanalytical Chemistry*

Received date: 24 October 2017

Revised date: 18 December 2017

Accepted date: 20 December 2017

Please cite this article as: Wojciech J. Stepniowski, Marcin Moneta, Krzysztof Karczewski, Marta Michalska-Domanska, Tomasz Czujko, Johannes M.C. Mol, Josephus G. Buijnsters, Fabrication of copper nanowires via electrodeposition in anodic aluminum oxide templates formed by combined hard anodizing and electrochemical barrier layer thinning. The address for the corresponding author was captured as affiliation for all authors. Please check if appropriate. Jeac(2017), <https://doi.org/10.1016/j.jelechem.2017.12.052>

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templates formed by combined hard anodizing and electrochemical barrier layer
thinning**

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Keywords: anodizing; anodic aluminum oxide; self-organization; hard anodizing; electrochemical barrier layer thinning; electrodeposition; copper nanowires

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